

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Dureseti CHIDAMBARRAO, et al. Group Art Unit: 2814
Appln. No. : 10/605,108 Examiner: PHAM, Long
Filed : September 9, 2003 Confirmation No. 2107
For : METHOD FOR REDUCED N+ DIFFUSION IN STRAINED SI
ON SI/GE SUBSTRATE

NOTICE OF APPEAL

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Window, Mail Stop AF
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Sir:

Applicant hereby appeals to the Board of Patent Appeals and Interferences from the Final Official Action of June 8, 2006 finally rejecting claims 16-18, 22-28 and 30-39. The following items are enclosed herewith:

- Payment in the amount of \$ 500.00 for the payment of the appeal fee as set forth in 37 C.F.R. 41.20(b)(1).
- A Request for Pre-Appeal Brief Review.

Please charge any additional fees necessary for consideration of the papers filed herein and refund excess payments to Deposit Account No. 09-0458.

Respectfully submitted,
Dureseti CHIDAMBARRAO, et al.



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August 23, 2006
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